



JOERG-UWE SZIPL, President

born in Chicago, Illinois in 1960. He graduated with a degree in Chemistry (B.A.) from Johns Hopkins University in 1982. In 1983-84 Mr. Szipl was a Doctoral Stipendiary of the Max-Planck-Institute in Muehlheim a.d. Ruhr, Germany where he conducted research in Biophysical Chemistry. He received his law degree (J.D.) from George Washington University in 1987.

Presently, Mr. Szipl represents clients in such diverse technologies as computer software, electronics, physics, chemistry and polymer science, pharmaceuticals and biotechnology, automobile technology, simple consumer products and heavy industry, including, e.g., steelmaking, and heavy machinery.

He is admitted to practice in Virginia, in Pennsylvania, in the District of Columbia, before the United States Patent and Trademark Office, before the U.S. District Court of the District of Columbia and the Eastern District of Virginia, before the U.S. Court of Appeals for the Federal Circuit (CAFC), before the U.S. Court of Appeals for the District of Columbia Circuit, and before the U.S. Supreme Court. He is a member of the Bar Association of the District of Columbia, the Federal Circuit Bar Association, the American Intellectual Property Law Association (A.I.P.L.A.), the Intellectual Property Owners association, the Japan Chamber of Commerce (D.C.), and the Licensing Executives Society. He has been Co-Chairman of the select U.S.-Japan Study Group of the A.I.P.L.A. and lectures with this group in the U.S. and Japan. He was an associate with Cushman, Darby and Cushman, Washington, D.C. and a consultant with Nakamura and Partners, Tokyo, Japan before joining Griffin & Szipl, P.C. as a partner. Mr. Szipl became president of the firm in April of 2000. Mr. Szipl practices in the areas of intellectual property litigation, patent, and trademark prosecution, and licensing. He has litigated patent, trademark and copyright cases. In addition, he has worked on complex international licensing negotiations and international arbitrations.

Mr. Szipl is a frequent lecturer on intellectual property protection, enforcement, and licensing topics in the U.S. and abroad. He has lectured extensively in Europe and Asia. He has been a lecturer on issues of Biotechnology law and Licensing for the Post-Graduate Program in Intellectual Property of the Swiss Federal Institute of Technology (ETH) in Zurich. He has also lectured on Intellectual Property at the Johns Hopkins University in Baltimore, MD, USA, and frequently lectures for the Japan Intellectual Property Association, Japan Patent Attorney's Association and the Customs Intellectual Property Information Center. In addition, Mr. Szipl has had many articles and monographs published on various aspects of intellectual property law and practice. He is a frequent contributor to Patent, the Journal of the Intellectual Property Association (JIPA).

Mr. Szipl is fluent in German and Japanese and conversant in French and Italian. Copies of his published articles are available upon request.